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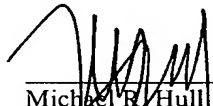


PATENT
30205/38082

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application of: Geun Su Lee et al.)
Serial No.: 10/079,348)
Filed: February 20, 2002)
For: Photoresist Monomers, Polymers)
Thereof and Photoresist Compositions)
Containing the Same)
Group Art Unit: 1752)
Examiner: Rosemary E. Ashton)

I hereby certify that this paper and the documents referred to as enclosed therewith are being deposited with the United States Postal Service as first class mail, postage prepaid, on **April 27, 2004**, in an envelope addressed to Commissioner for Patents, P.O. Box 1450, Alexandria, Virginia 22313-1450



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AMENDMENT

Commissioner for Patents
P.O. Box 1450
Alexandria, Virginia 22313-1450

Sir:

In response to the office action mailed on March 4, 2004, please amend the above-identified patent application as follows.

Amendments to the claims and a complete listing of the claims begin on page 2 of this paper.

Remarks begin on page 11 of this paper.